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45. (CURRENTLY AMENDED) A high reflectivity micro mirror, comprising:

a homogeneous monolithic bulk crystal silicon having an anisotropic body with several crystalline planes;

a <u>fixed</u> mirror surface co-extensive with an anisotropically etched portion of a selected one of the several crystalline planes, <u>the mirror surface being positioned internally</u> within the body, with only that portion of the selected crystalline plane required as the mirror surface being exposed; and

an inlet passage and an outlet passage anistropically etched independent of crystalline planes, which intersect at the selected one of the several crystalline planes.

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